

Docket No.: 071971-0569

PATENT

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of	:	Customer No.: 53080
	:	
Akio MISAKA	:	Confirmation No.: 7423
	:	
Application No.: 10/576,120	:	Group Art Unit: 1795
	:	
Filed: April 18, 2006	:	Examiner: Rashid A. ALAM
	:	
For: PHOTOMASK (as amended)	:	

AMENDMENT TO ACCOMPANY RCE

Mail Stop RCE
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

In response to the Office Action dated August 21, 2009, wherein a three-month shortened statutory period for response is set to expire on November 21, 2009, Applicant respectfully requests reconsideration of the above-identified application in view of the following amendments and remarks. A request for continued examination is being concurrently filed herewith.